

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant	:	Hada et al.
Appl. No.	:	10/563,501
Filed	:	January 5, 2006
For	:	POSITIVE RESIST COMPOSITION AND METHOD FOR FORMING RESIST PATTERN USING SAME
Examiner	:	Lee, Sin J..
Group Art Unit	:	1795

**AMENDMENT AND RESPONSE TO OFFICE ACTION****Mail Stop Amendment**

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action mailed **February 8, 2008**, please consider the following amendments and remarks:

**Amendments to the claims** are reflected in **the listing of claims** which begins on page 2 of this paper.

**Remarks/Arguments** begin on page 9 of this paper.